

Photocatalytic NO_x abatement: Why the selectivity matters

Jonathan Z. Bloh,^{a,‡} Andrea Folli,^{a,b} and Donald E. Macphee^{*a}

Supplementary Information

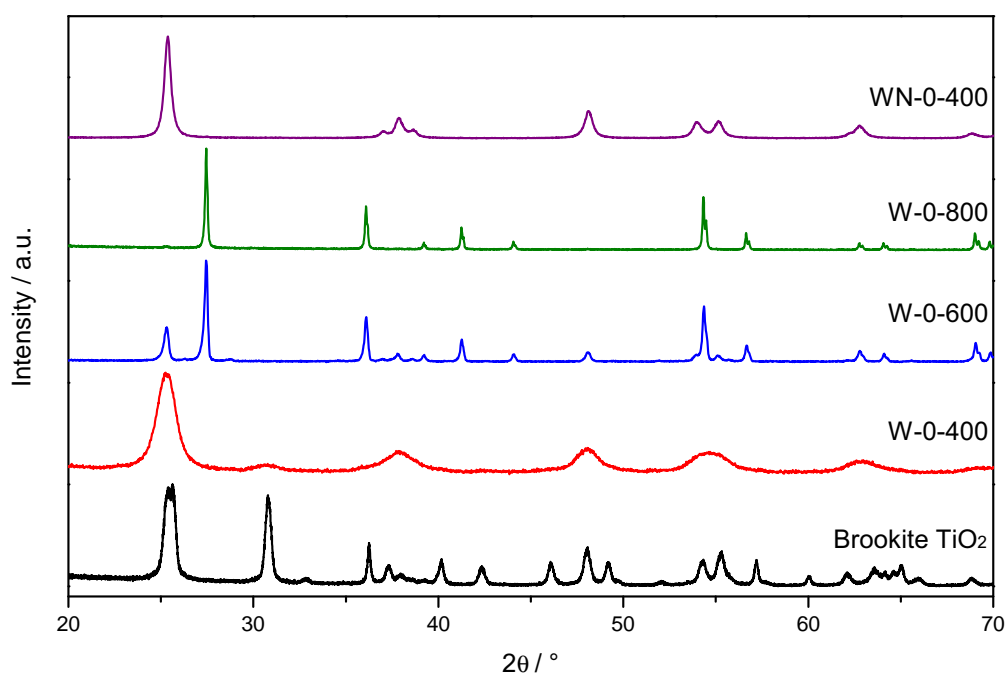


Figure S1 The XRD patterns of the synthesised samples

^a University of Aberdeen, Department of Chemistry, Meston Walk, Aberdeen AB24 3UE, United Kingdom.; E-mail: d.e.macphee@abdn.ac.uk

^b Danish Technological Institute, Gregersensvej 4, 2630 Taastrup, Denmark.

[‡] Present address: DECHEMA Research Institute, Theodor-Heuss-Allee 25, 60486 Frankfurt am Main, Germany.; E-mail: bloh@dechema.de

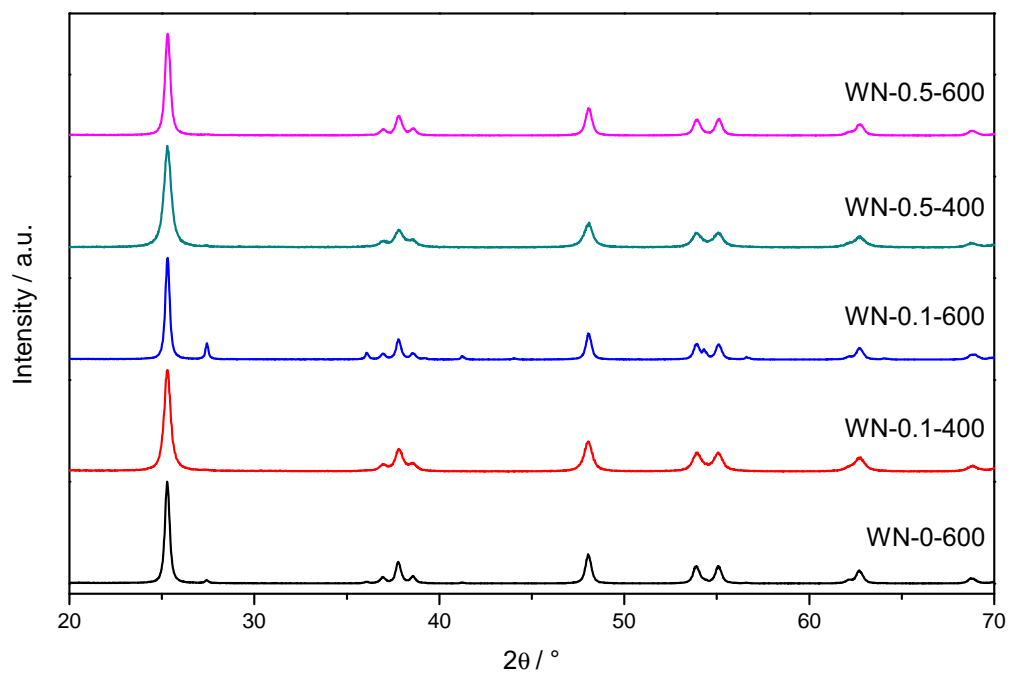


Figure S2 The XRD patterns of the synthesised samples

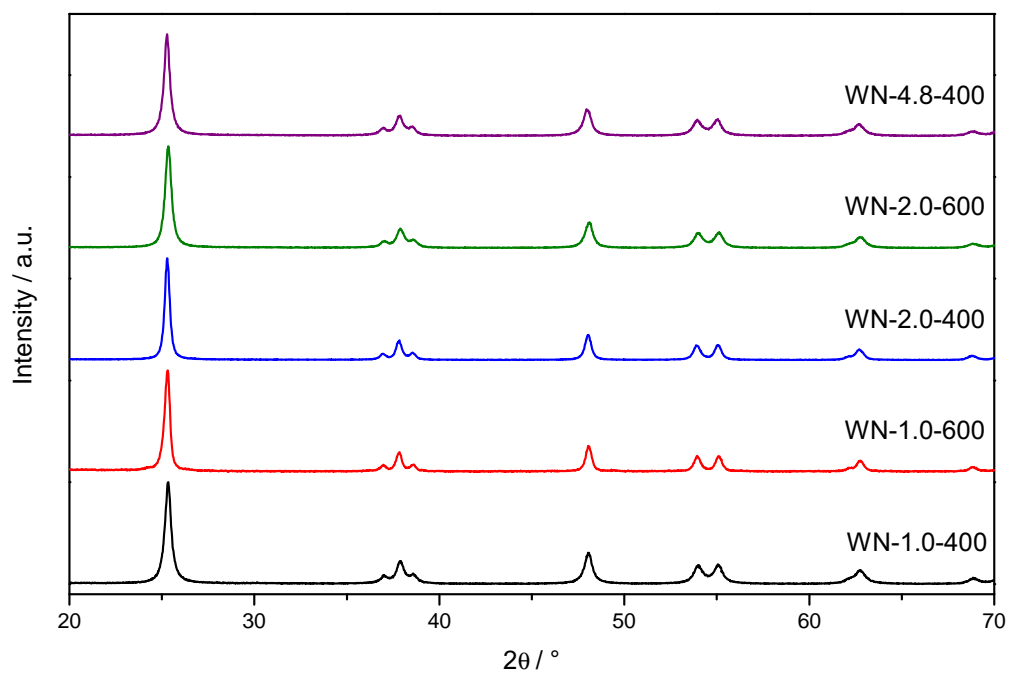


Figure S3 The XRD patterns of the synthesised samples

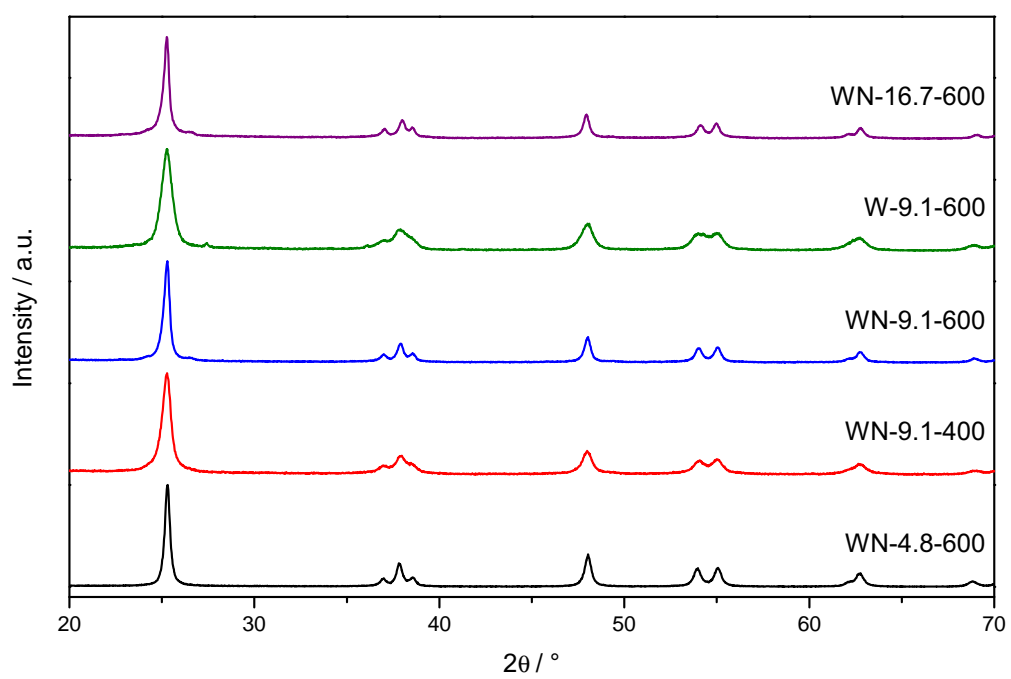


Figure S4 The XRD patterns of the synthesised samples